- 1. (Currently Amended) A method for fractional wounding of skin, comprising:

  applying (i) at least one chromophore one or more chromophores in a

  specific pattern to a predetermined area of skin, wherein the specific pattern corresponds
  to a desired pattern of fractional wounding;; and
- (ii) applying at least one of heat and/or or electromagnetic radiation to the predetermined area of skin.
- 2. (Currently Amended) The method of claim 1 wherein the specific pattern of the <u>at</u> least one chromophore one or more chromophores is applied as a layer.
- 3. (Currently Amended) The method of claim 2 1, further comprising wherein the layer application comprises applying the one or more chromophores to the skin and removing a first portion of the at least one chromophore one or more chromophores from the surface of the skin, wherein a second portion of the at least one chromophore one or more chromophores remains in pores of the skin.
- 4. (Currently Amended) The method of claim 3 wherein the <u>at least one</u> chromophore one or more chromophores is applied to skin as a powder.
- 5. (Currently Amended) The method of claim 1 wherein the specific pattern of the one or more chromophores is applied by using at least one of a grid, a mesh, a roller, a stamp or a stencil.

- 6. (Currently Amended) The method of claim 1 wherein the specific pattern of the one or more chromophores is applied to the skin with using an attachment medium.
- 7. (Original) The method of claim 6 wherein the attachment medium is an adhesive.
- 8. (Original) The method of claim 6 wherein the attachment medium is light-activated.
- 9. (Currently Amended) The method of claim 6 7 wherein the attachment medium is at least one of an acrylide, a derma-bond or a glue.
- 10. (Canceled)
- 11. (Currently Amended) A method for fractional wounding of skin, comprising; applying (i) at least one chromophore one or more chromophores to a predetermined area of skin;
- (ii) applying a mask with a specific pattern over the predetermined area of skin, wherein the specific pattern corresponds to a desired pattern of fractional wounding; and
  - (iii) applying heat and/or electromagnetic radiation.

12. (Original)	The method of	claim 11 wherein the fractional wounding occurs where the
mask is in contact with the skin.		
13. (Currently A	Amended)	The method of claim 11 wherein the mask is <u>at least one of</u>
a grid, a mesh, a roller, a stamp or a stencil.		
14. (Canceled)		
15. (Canceled)		
16. (Original)	The method of	f claim 11 wherein the mask protects the skin from
fractional woun	ding and wher	ein the fractional wounding occurs where the skin is not in
contact with the	mask.	
17. (Currently A	Amended)	The method of claim 16 wherein the mask is at least one of
a grid, a mesh o	r a stencil.	
18. (Canceled)		
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19. (Canceled)		

- 20. (Currently Amended) The method of claim 16 wherein the mask comprises one or more at least one chromophore reflectors.
- 21. (Currently Amended) The method of claim 20 wherein the one or more at least one of a glass bead, a gold flake, a metal particle, a mirrored glass bead, a salt crystal, or a silica, or any combination thereof.
- 22. (Currently Amended) The method of claim 1 or 11 wherein the <u>at least one</u> chromophore comprises carbon.
- 23. (Currently Amended) The method of claim 1 or 11 wherein the <u>at least one</u> chromophore is a phase transition chromophore.
- 24. (Original) The method of claim 23 wherein the phase transition chromophore comprises paraffin.
- 25. (Currently Amended) The method of claim 1 or 11 wherein the specific pattern comprises at least one one or more lines.
- 26. (Canceled)